

REMARKS

Election Requirement

The Examiner has required Applicants to elect one of the following patentably distinct species of the invention:

Species I. illustrated in Figure 7;

Species II. illustrated in Figure 10; or,

Species III. illustrated in Figure 11.

Applicants hereby elect Species II, illustrated in Figure 10 and believe that claims 1-13 are readable on the elected species.

Claim Amendments

Claims 8-13 have been amended to properly depend from independent claim 7.

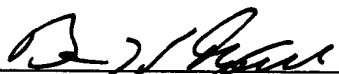
Summary

An early action on the merits of this application is respectfully requested. Should any points remain in issue, which the Examiner feels could best be resolved by either a personal or a telephone interview, it is urged that Applicants' local attorney be contacted at the exchange listed below.

Respectfully submitted,

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By:


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VERSION WITH MARKINGS TO SHOW CHANGES MADE

IN THE CLAIMS:

Claims 8-13 have been amended as follows:

--8. (Amended) The method of Claim [1] Z, wherein a size of said contact hole pattern is larger than a size of said independent spot pattern.

9. (Amended) The method of Claim [1] Z, wherein sizes and shapes of said independent spot patterns can be adjusted to control roughness degrees of said pixel electrode.

10. (Amended) The method of Claim [1] Z, wherein sizes and shapes of said independent spot patterns can be adjusted to control roughness degrees of said photosensitive passivation layer.

11. (Amended) The method of Claim [1] Z, wherein said independent spot patterns are defined by forming hollow areas on said mask.

12. (Amended) The method of Claim [1] Z, wherein said independent sport patterns are defined by forming the covering area on said mask with chromium films.

13. (Amended) The method of Claim [1] Z, wherein a first distance between two adjacent said independent spot patterns is smaller than a resolution of an exposure system while a second distance between adjacent said independent spot pattern and said contact hole pattern is larger than said resolution of said exposure system.--

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